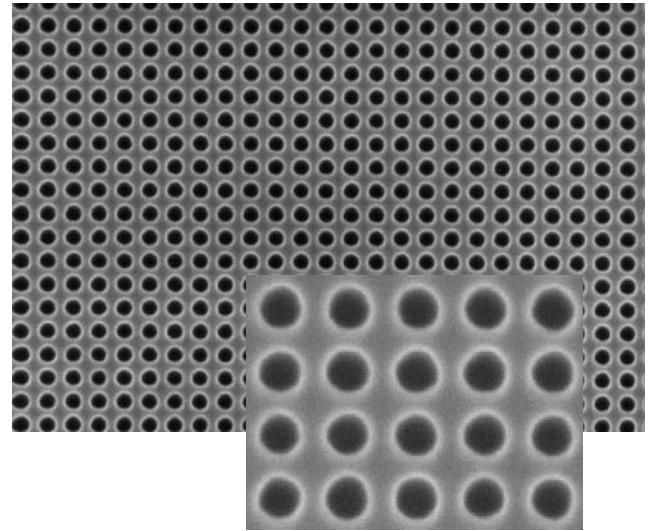


NANOIMPRINT TEMPLATE

35 nm HALF-PITCH NANOHOLE ARRAY

High-quality nanohole array

- Nanoholes on a square grid
- Pitch 70nm
- Field size 0.4 x 0.4 mm²
- Si chip size 15 mm x 15 mm
- Etch depth 50 nm
- Hole density 131 Gholes /inch²
- Anti-stick coating available



Applications

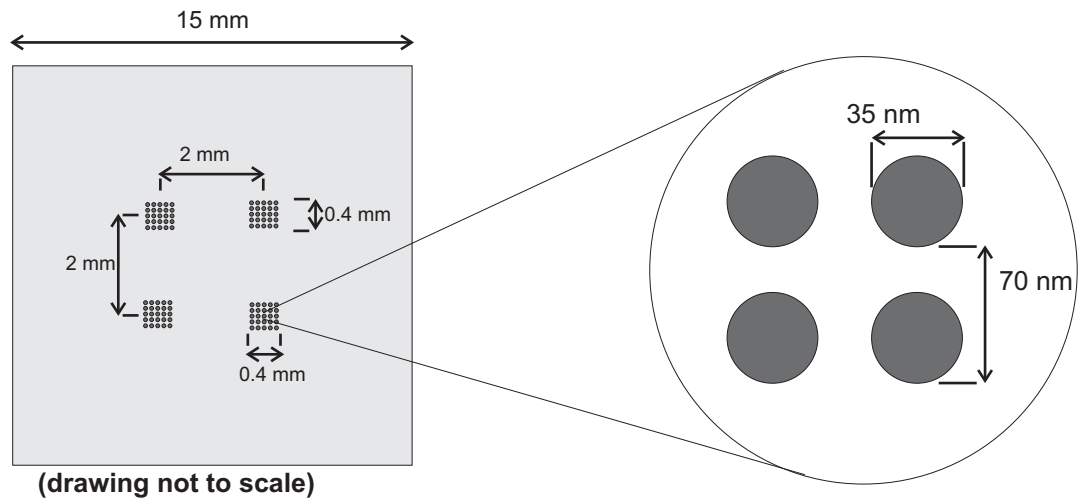
NIL process development

Nanophotonics

Nanomagnetics - data storage

Self-assembly templates

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Larger area and custom-made templates available